



JPW

Docket No.: SON-2413/DIV
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:

Shigeru Moriya, et al.

Confirmation No.: 3815

Application No.: 10/689,098

Art Unit: 1756

Filed: October 21, 2003

Examiner: Stephen D. Rosasco

For: MASK, METHOD OF PRODUCING MASK,
AND METHOD OF PRODUCING
SEMICONDUCTOR DEVICE

SUPPLEMENTAL AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

INTRODUCTORY COMMENTS

In full and timely further response to the Official Action dated March 13, 2006,
please supplement the prior amendment to the above-identified U.S. patent application as
follows:

Amendments to the Claims are reflected in the listing of claims which begins on
page 2 of this paper.

Remarks/Arguments begin on page 7 of this paper.